

Phase composition and properties of solid solutions of GdFeO_3 – GdInO_3 bulks

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Abstract

Solid solutions of the GdFeO_3 – GdInO_3 system were prepared at 1550 °C by ceramic powder processing. The formulated composition was $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ (GFI) with the indium contents at $x = 0, 0.25, 0.5, 0.75$, and 1.0. A stable phase of $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ in our system was identified by X-ray diffraction and phase composition analysis. Multi-phase morphologies were observed for GFI bulks with $x = 0.5$ and 0.75. Dielectric and electrical properties of the GFI bulks were investigated. The addition of 25% In^{3+} in GdFeO_3 had an obvious enhancement in polarization and led to an elevated resonance frequency. Dielectric properties of GFI bulks except GdInO_3 were strongly dependent upon the test frequency, which corresponded to the response of polarization mechanism. GdInO_3 displayed as a stable dielectric, which was frequency- and temperature-insensitive. GdInO_3 was thermally activated and became leaky until above 600 °C.

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1. Introduction

Rare-earth orthoferrites (RFeO_3 , R = rare earth) are anti-ferromagnetic with weak superlattice ferromagnetism and are of both scientific and technical interest in optic-magneto storage logic events, memory-based devices and other related applications [1,2]. Rare-earth orthoferrites have a perovskite (ABO_3) structure, which is usually distorted from the cubic to orthorhombic form with space group $Pbnm$ or the GdFeO_3 (GFO)-type form, and are uniaxial with orthorhombic c -axis magnetically favored [3]. There are also tetragonal, rhombohedral, monoclinic, and triclinic perovskites which are originated from the structure deviations of the ideal cubic structure through the tilting of the BO_6 octahedra [4]. Even greater deviations can lead to a structure with hexagonal $P6_3cm$ crystallography. Other GdFeO_3 -type compounds are RMO_3 , where M represents elements of Mn, Fe, Cr, Al, Ga, V, Ti, etc. [3]. Instead of rare-earth orthoferrites, BiFeO_3 has been the most studied multiferroic

material. Initially suffering a problem of high leakage current to inhibit ferroelectricity, BiFeO_3 films have improved performance by fabricating thin films with different epitaxial heterostructures [5] or on different buffered substrates [6,7]. Chemical substitutions on A or B sites of the ABO_3 perovskite structure with isovalent or aliovalent ions have been the most studied area in property modifications. $(\text{Bi}_{0.7}\text{Ba}_{0.3})(\text{Fe}_{0.7}\text{Ti}_{0.3})\text{O}_3$ films and Cr-doped, Ti^{4+} donor-doped, and La-doped BiFeO_3 films have been investigated with improved performance [8–11].

GdInO_3 has a perovskite structure with the hexagonal $P6_3cm$ crystallography [12]. Contributed from oxygen conductivity, GdInO_3 has a potential to be used as the electrolyte of solid oxide fuel cells. Based upon our preliminary experiments, it was observed that GdInO_3 dissolved into GdFeO_3 to a large degree. Therefore, the solid solution of the orthorhombic GdFeO_3 –hexagonal GdInO_3 system aroused our interests in investigating their phase composition and properties. This system was prepared based upon the chemical formula of $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ with $x = 0, 0.25, 0.5, 0.75$, and 1.0 or abbreviated as GFI- x .

2. Experimental

GFI bulks were prepared by a conventional ceramic route. Gd_2O_3 , In_2O_3 , and Fe_2O_3 ceramic powders were the raw

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materials. After mixing powders according to the formulated composition, the mixture was firstly calcined at 800 °C for 3 h. A second-calcination process was conducted at 950 °C for 6 h after sieving. After ball milling and sieving, the pressed pellets were sintered at 1550 °C in air for 3 h. Before the microstructure observations by scanning electron microscopy (SEM), the polished pellets were thermally etched at 1175 °C for 20 min. High temperature silver paste was applied on the two sides of pellets and dried at 600 °C for 20 min for the purpose of measuring dielectric properties. Crystallinity of GFI bulks was examined by X-ray diffraction analysis (XRD, Rigaku D/Max 2500, Japan). Surface morphologies of films were observed by scanning electron microscopy (SEM, Hitachi S-3500H, Japan). The energy dispersive spectroscopy (EDS) equipped on SEM was used to analyze the phase composition. Dielectric properties were measured with a precision impedance–capacitance–resistance meter (Model 4284A, Agilent Technologies, USA) at frequencies of 10^2 to 10^6 Hz. Leakage current was obtained by using an electrometer/high-resistance meter (Model 6517a, Keithley Instruments, Inc., USA).

3. Results and discussion

X-ray diffraction (XRD) patterns of $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks are shown in Fig. 1. Pure GdFeO_3 bulk displayed as a single phase of the orthorhombic GdFeO_3 -type perovskite with a random orientation. The substitution of 25% indium for Fe^{3+} kept the same structure as the pure GdFeO_3 . The 25% solubility of indium in the Fe site was feasible for GdFeO_3 to form the solid solution of $\text{Gd}(\text{Fe}_{0.75}\text{In}_{0.25})\text{O}_3$ without a second phase. The GFI-0.5 bulk displayed a major GdFeO_3 structure but contained other phases to be identified. Pure GdInO_3 bulk also displayed a single phase of the hexagonal GdInO_3 perovskite with a random orientation. The $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$ bulk had the hexagonal GdInO_3 phase and other GdFeO_3 -structure phases. For the GFI-0.25 bulk, diffraction peaks of the perovskite

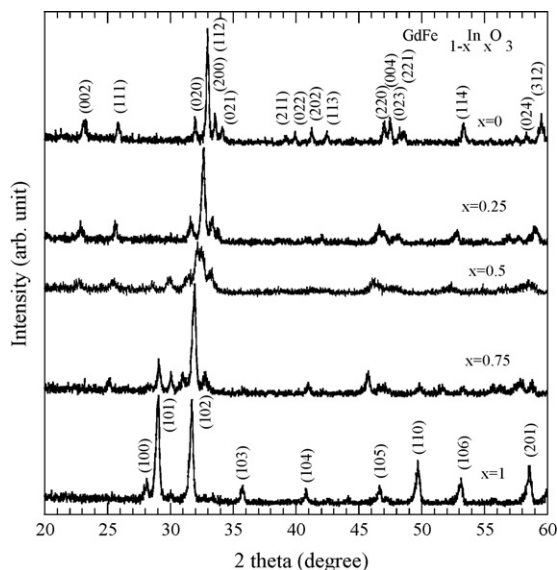


Fig. 1. X-ray diffraction patterns for 1550 °C-sintered $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents.

structure obviously shifted to a lower angle, indicating an increase in cell dimensions. The substitution of smaller Fe^{3+} [$r(\text{Fe}^{3+}) = 0.64$ Å of Ahrens ionic radius] with larger In^{3+} [$r(\text{In}^{3+}) = 0.81$ Å] is expected to expand the cell dimension and to lead to distortion caused by the dilated cells surrounded by the non-substituted cells [13]. On the other hand, the GFI-0.75 bulk showed an insignificant peak shift after substituting 25% Fe^{3+} for In^{3+} .

Fig. 2(a–c) shows the SEM images of 1550 °C-sintered GFI- x bulks for the indium contents at $x = 0$, 0.25, and 1.0. GFI-0, GFI-0.25, and GFI-1.0 displayed single-phase morphologies. The higher indium content led to a finer grain size. Pure GdInO_3 had a smallest grain size. The compositional analyses in each grain size coincided with their own formulated composition. No other second phases were detected. Surface morphology of the GFI-0.25 or $\text{Gd}(\text{Fe}_{0.75}\text{In}_{0.25})\text{O}_3$ bulk showed many small plates

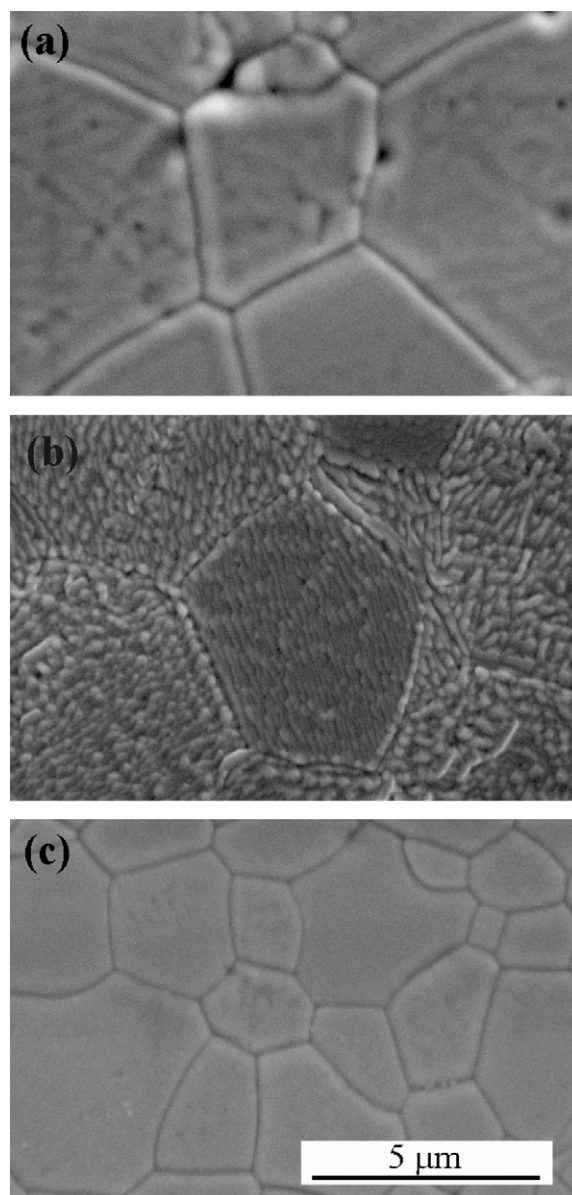


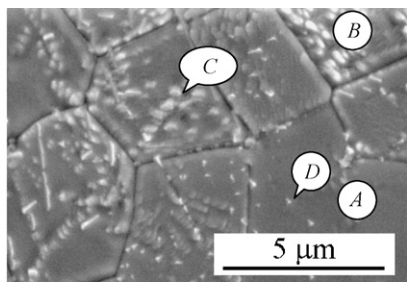
Fig. 2. SEM surface morphologies of 1550 °C-sintered $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with the indium contents at (a) $x = 0$, (b) $x = 0.25$, and (c) $x = 1.0$.

in each grain. These small plates can be related to anti-phases or electrical domains.

Fig. 3 displays the SEM image and the EDS element analysis of 1550 °C-sintered $\text{Gd}(\text{Fe}_{0.5}\text{In}_{0.5})\text{O}_3$ or GFI-0.5 bulk. The analysis at the (A) area obtained the element composition coincident with the formulated composition of $\text{Gd}(\text{Fe}_{0.5}\text{In}_{0.5})\text{O}_3$ or $\text{Gd}(\text{Fe}_{1/2}\text{In}_{1/2})\text{O}_3$. The element analysis at the (B) area with much more second phases had less Fe content and indicated the formation of Gd_5InO_9 or $5\text{Gd}_2\text{O}_3 \cdot \text{In}_2\text{O}_3$. The element analyses at the (C) and (D) points, however, demonstrated the different distributions of Fe^{3+} and In^{3+} at the B site of ABO_3 . It was the phase of $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ with one third of the B sites occupied by Fe^{3+} and two thirds by In^{3+} .

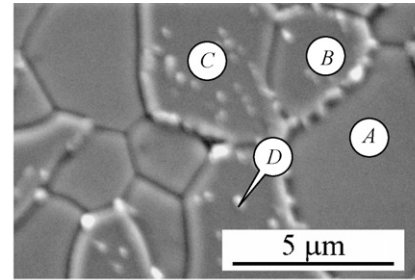
Fig. 4 displays the SEM image and the EDS element analysis of 1550 °C-sintered $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$ or GFI-0.75 bulk. The analyses at the (B) area and the (D) point obtained the element composition coincident with the formulated composition of $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$ or $\text{Gd}(\text{Fe}_{1/4}\text{In}_{3/4})\text{O}_3$. The grain at the analysis (A) area did not exist the second phase. The element analysis at the (A) area indicated a Fe-less and In-rich phase with GdInO_3 as the major structure. The phase at the (A) area, therefore, was Fe-doped GdInO_3 . The analysis at the (C) area identified the existence of the $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ when the indium content in GFI was high.

Different phase compositions for the mixed GdFeO_3 – GdInO_3 system were observed, which included $\text{Gd}(\text{Fe}_{3/4}\text{In}_{1/4})\text{O}_3$, $\text{Gd}(\text{Fe}_{1/2}\text{In}_{1/2})\text{O}_3$, $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$, and $\text{Gd}(\text{Fe}_{1/4}\text{In}_{3/4})\text{O}_3$. GdFeO_3 can dissolve up to 25% In^{3+} without forming second phases. For the formulated composition of $\text{Gd}(\text{Fe}_{0.5}\text{In}_{0.5})\text{O}_3$, some In^{3+} -rich $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ phase can form accompanying by the formation of In^{3+} -less Gd_5InO_9 to maintain the mass balance. For the formulated composition of $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$ with much more the indium content, In^{3+} -less $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ phase formed accompanying by the formation of In^{3+} -rich and Fe-doped GdInO_3 to maintain the mass balance. Therefore, the



| EDS element analysis | | | | |
|----------------------|------|------|------|------|
| Atomic % site | Gd | Fe | In | O |
| (A) area | 20.7 | 9.81 | 10.6 | 58.0 |
| (B) area | 33.8 | 0.38 | 7.33 | 58.5 |
| (C) point | 19.3 | 5.75 | 10.4 | 64.6 |
| (D) point | 18.6 | 6.77 | 10.4 | 64.2 |

Fig. 3. SEM surface morphology of 1550 °C-sintered $\text{Gd}(\text{Fe}_{0.5}\text{In}_{0.5})\text{O}_3$ bulks and its EDS element analyses at different area and points.



| EDS element analysis | | | | |
|----------------------|------|------|------|------|
| Atomic % site | Gd | Fe | In | O |
| (A) area | 21.0 | 3.08 | 18.2 | 57.7 |
| (B) area | 20.9 | 4.76 | 15.3 | 59.1 |
| (C) area | 19.7 | 6.56 | 14.5 | 59.3 |
| (D) point | 19.0 | 4.78 | 13.3 | 62.9 |

Fig. 4. SEM surface morphology of 1550 °C-sintered $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$ bulks and its EDS element analyses at different area and points.

$\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ phase is a thermodynamically stable phase and can easily exist at the condition with a higher indium content at the B site of the ABO_3 structure.

Fig. 5 shows the variations of (a) the dielectric constant (ϵ_r) and (b) the dissipation factor ($\tan \delta$) with test frequency for $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents. The ϵ_r values measured at 1 kHz and 1 MHz were 2485 and 50, 3680 and 120, 5070 and 50, 345 and 38, and 50 and 40 for GFI- x bulks with the indium contents at $x = 0, 0.25, 0.5, 0.75$, and 1.0, respectively. The $\tan \delta$ values measured at 1 kHz and 1 MHz

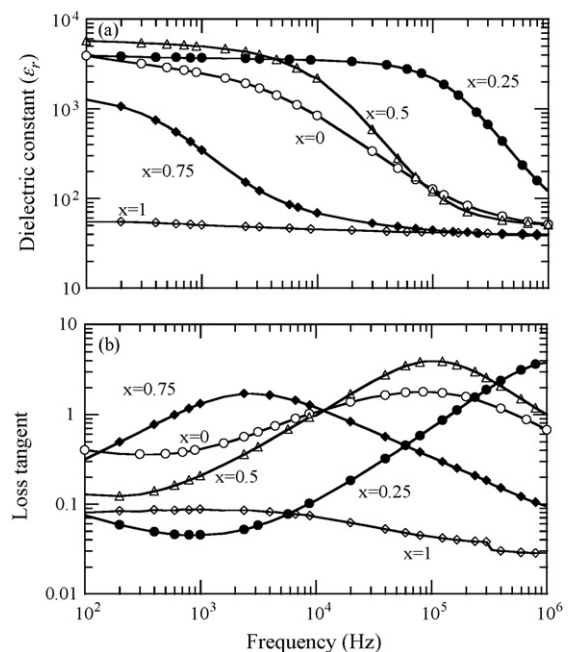


Fig. 5. The variations of (a) dielectric constant and (b) dielectric loss tangent with the test frequency for 1550 °C-sintered $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents.

were 0.41 and 0.68, 0.05 and 3.86, 0.21 and 0.99, 1.31 and 0.09, and 0.09 and 0.03 for the GFI- x bulks with the indium contents at $x = 0, 0.25, 0.5, 0.75$, and 1.0 , respectively. GdInO_3 remained frequency-independent with constant ϵ_r and low $\tan \delta$, while other compositions displayed a relaxation with a high \rightarrow low ϵ_r change and a maximal loss peak at the resonance frequency (ω_r). This relaxation corresponds to the transition of dipolar polarization (lower frequency) to the ionic polarization (higher frequency). The ω_r values were 10^5 , $\sim 10^6$, 1.2×10^5 , and 2×10^3 Hz for GFI- x bulks with the indium contents at $x = 0, 0.25, 0.5$, and 0.75 , respectively. Basically, the resonance frequency of GdFeO_3 should shift to lower frequency or the relaxation time take longer as the substitutes of In^{3+} have a heavier mass than Fe^{3+} . However, the addition of 25% In^{3+} shifted the resonance frequency more to higher frequency, indicating the response of dipolar polarization to the field frequency becomes faster. The special behavior for the 25% In^{3+} -added GdFeO_3 is attributed to the enhanced electrical polarization caused by the addition of larger ions to substitute Fe^{3+} , which leads to the dilation of unit cell (Fig. 1), lattice distortion, and enhanced polarization. For GFI-0.5 bulk, the contribution of enhanced polarization becomes less. For those with $x > 0.5$, they were dielectrics without enhanced polarization. That is to say, there is no dipolar polarization for GdInO_3 and GFI-0.75. Small plates in the grains of GFI-0.25 bulks (Fig. 2(b)) can be the evidence for the enhanced polarization.

Fig. 6 shows the variations of (a) the dielectric constant (ϵ_r) and (b) the dissipation factor ($\tan \delta$) with test temperature under a test frequency of 1 MHz for $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents. ϵ_r reached a maximum with test temperature for the GFI bulks except for GdInO_3 . GdInO_3 demonstrated temperature-stable characteristics in dielectrics. Up to 600°C , ϵ_r of GdInO_3 remained constant and its loss

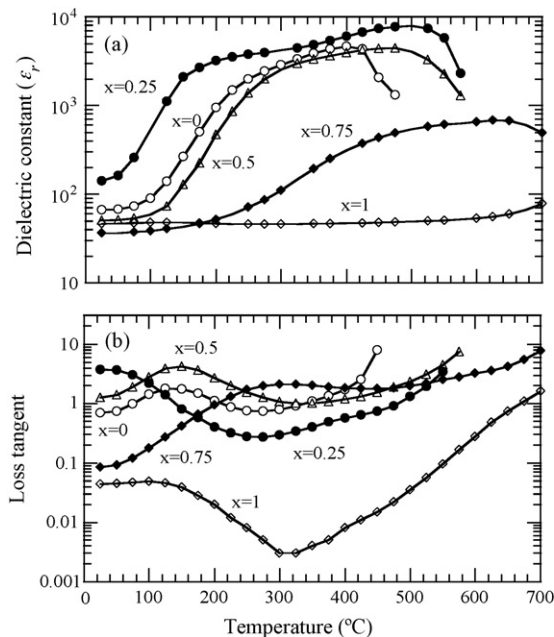


Fig. 6. The variations of (a) dielectric constant and (b) dielectric loss tangent with the measuring temperature for 1550°C -sintered $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents. The test frequency: 1 MHz.

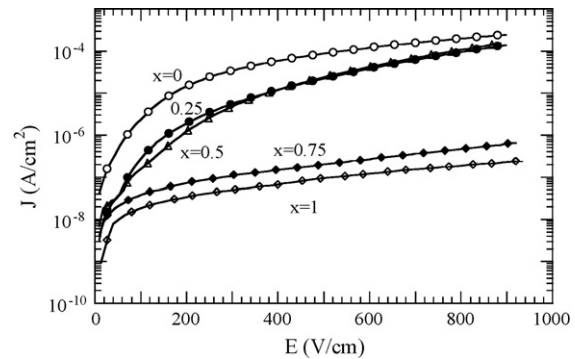


Fig. 7. The plot of $\log(\text{leakage current density})$ vs. electric field for 1550°C -sintered $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with different indium contents.

remained low. The maximal temperatures were 420, 520, 460, and 640°C for GFI- x bulks with the indium contents at $x = 0, 0.25, 0.5$, and 0.75 , respectively. After the maximal temperature, ϵ_r started to decrease, accompanying with a faster increase in $\tan \delta$. The variation of the maximal temperature with temperature for GFI- x bulks with different indium contents is in the same trend as the enhancement of polarization. The enhanced polarization for the 25% In^{3+} -added $\text{Gd}(\text{Fe},\text{In})\text{O}_3$ led to the increase of Curie temperature from 420 to 520°C , followed by lowering to 460°C for the 50% In^{3+} -added $\text{Gd}(\text{Fe},\text{In})\text{O}_3$. Both of the GFI-0.75 and GFI-1.0 bulks, without the enhanced polarization, behaved like dielectrics and became leaky due to thermal activation at higher test temperatures above 600°C .

Fig. 7 shows the variations of leakage current density and applied electric field in the form of $\log(J)$ versus E for GFI- x bulks at different indium contents. The addition of indium to GdFeO_3 improved the problem of leakage current. The resistivity measured at room temperature under 400 V cm^{-1} applied field was 6.8×10^6 , 3.3×10^7 , 3.3×10^7 , 2.7×10^9 and $6.0 \times 10^9 \Omega\text{ cm}$ for GFI- x bulks with the indium contents at $x = 0, 0.25, 0.5, 0.75$, and 1.0 , respectively. At low applied dc field, all bulks had a linear dependence of $\log(J)$ versus $E^{1/2}$, which is identified as Schottky emission conduction, indicating the electrode/bulk interface controlled the dc conduction at low field. For the space charge-limited conduction with deep traps, it follows a power law relation, $J \propto E^m$ [14,15]. The J - E curves of GFI-0, GFI-0.25, and GFI-0.5, including the higher field part, can be fitted well with the modified Langmuir–Child law [16]:

$$J = aE + bE^2$$

with $a = 3.86 \times 10^{-8} \Omega^{-1} \text{ cm}^{-1}$ and $b = 2.63 \times 10^{-10} \Omega^{-1} \text{ V}^{-1}$ for GdFeO_3 . This indicates that space charge-limited conduction is still dominant in the higher field region for GFI-0, GFI-0.25, and GFI-0.5 bulks. There is a transition from the Schottky emission (interface barrier) to space charge-limited (bulk barrier) conduction as the applied field increases. Oxygen vacancies have been related to the origin of space charges in some electronic ceramics [17]. The more oxygen vacancies, the more free carriers the bulks can create. The addition of In^{3+} into Fe^{3+} of GdFeO_3 leads to the decrease in the number of

oxygen vacancies and free carriers, which results in higher resistivity [10]. For GFI-0.75 and GFI-1.0, an exponential function, i.e., $\log(J) \propto E$, was observed, indicating that the conduction process is predominated by the field-assisted ionic conduction [14,15]. Therefore, the conduction mechanism can be changed from the space charge-limited conduction to the field-assisted ionic conduction as the indium content in $\text{Gd}(\text{Fe},\text{In})\text{O}_3$ becomes dominant. The occurrence of ionic conduction by ion species is attributed to the annihilation of oxygen vacancies. Therefore, the In^{3+} substitution for Fe^{3+} of GdFeO_3 can reduce the oxygen vacancies, favor the field-assisted ionic conduction, and lead to higher resistivity.

4. Conclusions

Orthorhombic GdFeO_3 , hexagonal GdInO_3 , and solid solutions of $\text{Gd}(\text{Fe},\text{In})\text{O}_3$ were sintered at 1550°C and investigated. GdFeO_3 can dissolve 25% In^{3+} without forming the second phase. A stable product of $\text{Gd}(\text{Fe}_{1/3}\text{In}_{2/3})\text{O}_3$ was found in sintered bulks with formulated compositions of $\text{Gd}(\text{Fe}_{0.5}\text{In}_{0.5})\text{O}_3$ and $\text{Gd}(\text{Fe}_{0.25}\text{In}_{0.75})\text{O}_3$. Dielectric properties of the GdFeO_3 – GdInO_3 system except GdInO_3 were quite frequency- and temperature-sensitive. The incorporation of In^{3+} into GdFeO_3 altered the dielectric and electrical properties. The resonance frequency increased up to 25% In^{3+} then decreased with further increasing the In^{3+} content. Combining with the microstructure observations of small plates in grains, the addition of 25% In^{3+} was expected to enhance polarization. The $\text{Gd}(\text{Fe}_{0.75}\text{In}_{0.25})\text{O}_3$ bulk had dielectric constant of 3680 and loss tangent of 0.045 under 1 kHz. $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks with x not larger than 0.5 performed like ferroelectrics while behaved like dielectrics for those with $x > 0.5$. For those with compositions close to GdInO_3 , $\text{Gd}(\text{Fe},\text{In})\text{O}_3$ bulks became stable in dielectrics and had lower leakage current. $\text{Gd}(\text{Fe}_{1-x}\text{In}_x)\text{O}_3$ bulks displayed a transition of space charge-

limited conduction to the field-assisted ionic conduction as the indium content increased to annihilate oxygen vacancies.

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